



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: **10/549,609**

Filing Date: September 20, 2005

Applicant: Tomoko AKAI et al.

Conf. No.: 8155

Group Art Unit: 1746

Examiner: Margaret Squalls

Title: METHOD FOR PRODUCING HIGH SILICATE GLASS AND
HIGH SILICATE GLASS (as amended)

Atty. Dkt. No.: 12480-000144/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
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January 20, 2011

AMENDMENT UNDER 37 C.F.R. § 1.114

Dear Sir:

In response to the Final Office Action (hereinafter 'Action') mailed on July 22, 2010 (the period for reply being extended three (3) months to January 22, 2011) and concurrently with the filing of a Request for Continued Examination (RCE), the following amendments and remarks are respectfully submitted in connection with the above-identified patent application.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	7	-	20	=	0
Independent	1	-	3	=	0